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(54) **Organic light emitting diode display and method for manufacturing the same**

Organische lichtemittierende Diodenanzeige und Verfahren zu deren Herstellung

Affichage de diode électroluminescente organique et son procédé de fabrication

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Description

BACKGROUND OF THE INVENTION

Field of the Invention

[0001] An organic light emitting diode (OLED) display and a manufacturing method thereof that improves durability and suppresses generation of a defect.

Description of the Related Art

[0002] An organic light emitting diode (OLED) display has a self-emissive characteristic in that, unlike the liquid crystal display, it does not need a separate light source such as a backlight. Therefore, the OLED display can have a reduced thickness and weight. In addition, since the OLED display has high-quality characteristics such as low power consumption, high luminance, fast reaction, and the like, the OLED display is drawing attention as a next generation display device for portable electronic devices.

[0003] Generally, the OLED display includes a display substrate having an OLED, an encapsulation substrate that is arranged opposite to the display substrate to protect the OLED, and a sealant that adheres and seals the display substrate and the encapsulation substrate together. An example of a display comprising organic light-emitting elements is provided in international patent application WO 2008/084743 where first partitions are provided to demarcate an organic light-emitting layer from adjacent other unit pixels, and a second partition is provided between the first partitions demarcating the organic light-emitting layer as to have a uniform coating thickness. Further examples can be found in US patent application 2007/194322 and in US patent application 2003/157740. Since an empty space is arranged between the display substrate and the encapsulation substrate, there is a problem in that the mechanical strength of the OLED display can be compromised upon external impact. For instance, provides an com

[0004] In order to address this problem, the empty space between the display substrate and the encapsulation substrate can be filled with a filler via a vacuum bonding process to make the OLED display less vulnerable to damage upon external impact. However, when the space between the display substrate and the encapsulation substrate is filled with the filler, the filler contacts the sealant arranged along edges of the display and encapsulation substrates. When this contact occurs, the filler can interfere with the hardening or curing process of the sealant. As a result, there is a problem in that the sealant may not stably seal and bond the display substrate to the encapsulation substrate.

SUMMARY OF THE INVENTION

[0005] The described technology has been made in an

effort to provide an organic light emitting diode (OLED) display having advantages of reducing vulnerability of the display to damage while suppressing defects.

[0006] According to the present invention, there is provided an organic light emitting diode (OLED) according to claim 1.

[0007] In addition, the present invention provides a method for manufacturing the OLED display in accordance with claim 6.

10 [0008] The thickness of the pixel defining layer may increase to the edges of the display substrate in a stepwise fashion. In this case, the pixel defining layer has a cross-section of a linear inclination structure.

15 [0009] According to an alternative embodiment, the thickness of the pixel defining layer gradually increases to the edges of the display substrate in a linear fashion. In this case, the pixel defining layer has a cross-section of a linear inclination structure.

20 [0010] At least one drop point can be arranged at a location in the display where the pixel defining layer has a relatively small thickness. Particularly, the drop point may be arranged at a location in the display where the pixel defining layer has a smallest thickness. In this connection it is particularly preferred that the thickness of the pixel defining layer varies in a stepwise fashion. The pixel defining layer can include a smallest thickness portion arranged about a drop point and a greatest thickness portion arranged at the edges of the display substrate, the thickness of the pixel defining layer gradually increasing from the smallest thickness portion to the greatest thickness portion. The pixel defining layer can have a cross-section of a step structure. The pixel defining layer can have a cross-section of a linear inclination structure. The OLED display can also include a plurality of spacers arranged on at least one of the display substrate and the encapsulation substrate to maintain an interval between the display substrate and the encapsulation substrate. Ones of the plurality of spacers can have lengths that vary according to location. The OLED display can include at least two separate drop points. The drop points can be arranged in a direction parallel to a long side of the display substrate.

35 [0011] The display substrate can further include an organic light emitting element, and the pixel defining layer can have an opening defining a light emitting region of the organic light emitting element. The pixel defining layer can include a smallest thickness portion arranged adjacent to and about the drop point and a greatest thickness portion arranged at the edges of the display substrate and the sealant can be arranged close to the greatest thickness portion of the pixel defining layer. The thickness of the pixel defining layer can gradually increase from the smallest thickness portion to the greatest thickness portion. The pixel defining layer can have a cross-section of a step structure. The pixel defining layer can have a cross-section of a linear inclination structure. The method can also include forming a plurality of spacers on at least one of the display substrate and the encapsulation substrate.

sulation substrate. Ones of the plurality of spacers can have lengths that vary according to location. The method can also include hardening the sealant while combining the display substrate and the encapsulation substrate together. The OLED display can include at least two separate drop points. Ones of the drop points can be arranged in a direction parallel to a long side of the display substrate.

BRIEF DESCRIPTION OF THE DRAWINGS

[0012] A more complete appreciation of the invention, and many of the attendant advantages thereof, will be readily apparent as the same becomes better understood by reference to the following detailed description when considered in conjunction with the accompanying drawings in which like reference symbols indicated the same or similar components, wherein:

FIG. 1 is a cross-sectional view of an organic light emitting diode (OLED) display according to the first exemplary embodiment of the present invention;

FIG. 2 is a top plan view of the organic light emitting diode (OLED) display of FIG. 1 focusing on the sealant and pixel defining layer;

FIG. 3 is a partial perspective view taken along the line III-III of FIG. 2;

FIG. 4 is a cross-sectional view showing a portion of a manufacturing process of the organic light emitting diode (OLED) display of FIG. 1;

FIG. 5 is a layout view illustrating an enlarged internal structure of the organic light emitting diode (OLED) display of FIG. 1;

FIG. 6 is a cross-sectional view taken along the line VI-VI of FIG. 5;

FIG. 7 is a top plan view of an organic light emitting diode (OLED) display according to the second exemplary embodiment of the present invention; and
FIG. 8 is a cross-sectional view of an organic light emitting diode (OLED) display according to the third exemplary embodiment of the present invention.

DETAILED DESCRIPTION OF THE INVENTION

[0013] The present invention will be described more fully hereinafter with reference to the accompanying drawings, in which exemplary embodiments of the invention are shown. As those skilled in the art would realize, the described embodiments may be modified in various different ways, without departing from the scope of the present invention as defined by the claims.

[0014] In addition, when describing a variety of exemplary embodiments, like reference numerals designate like elements that will be described in a first exemplary embodiment. Therefore, in other exemplary embodiments, only different elements will be described.

[0015] Accordingly, the drawings and description are to be regarded as illustrative in nature and not restrictive.

Like reference numerals designate like elements throughout the specification.

[0016] In order to clarify layers and regions, thicknesses and sizes thereof are exemplarily illustrated and thus the present invention is not limited thereto.

[0017] In the drawings, the thickness of layers, films, panels, regions, etc., are exaggerated for clarity. In addition, in order to clarify some layers and some regions, thicknesses and sizes thereof are enlarged in the drawings. It will be understood that when an element such as a layer, film, region, or substrate is referred to as being "on" another element, it can be directly on the other element or intervening elements may also be present.

[0018] Further, although an active matrix type of OLED display of a 2Tr-1Cap structure in which one pixel has two thin film transistors and one capacitor is illustrated in the accompanying drawings, the present invention is not limited thereto. Therefore, the OLED display may be formed with pixels each having three or more thin film transistors and two or more capacitors. In addition, the OLED display may be formed in a variety of structures by adding additional metal lines. Here, the pixel is a minimum unit that can display an image, and the OLED display displays an image using a plurality of the pixels.

[0019] Next, the first exemplary embodiment will be described with reference to FIG. 1 to FIG. 3.

[0020] As shown in FIG. 1, an organic light emitting diode (OLED) display 101 according to the first exemplary embodiment includes a display substrate 110, an encapsulation substrate 210, a sealant 350, and a filler 300. The display substrate 110 includes the first substrate main body 111, a driving circuit DC, an organic light emitting element 70, and a pixel defining layer 190 formed on the first substrate main body 111. The first substrate main body 111 may be made out of an insulating substrate such as glass, quartz, ceramic, or plastic, however the first exemplary embodiment is not limited thereto as the first substrate main body 111 can instead be made out of a metal substrate such as stainless steel.

[0021] The driving circuit DC includes thin film transistors 10 and 20 (as shown in FIG. 5) to drive the organic light emitting element 70. The organic light emitting element 70 emits light and displays images according to driving signals transmitted from the driving circuit DC.

[0022] The detailed structure of the organic light emitting element 70 and the driving circuit DC are shown in FIGS. 5 and 6, however the first exemplary embodiment is in no way limited to the structure shown in FIGS. 5 and 6 as the organic light emitting element 70 and the driving circuit DC may be variously modified within a range that can be easily realized by a person skilled in the art.

[0023] As shown in FIGS. 1 and 3, the pixel defining layer 190 has a plurality of openings 195 defining light emitting regions of organic light emitting elements 70. Also, the pixel defining layer 190 has a thickness that varies by location, for instance in a stepwise fashion. The portion of the pixel defining layer 190 having the greatest thickness is disposed at the edge of the display substrate

110, and the portion of the pixel defining layer 190 having the smallest thickness is disposed at the central part of the display substrate 110. Also, as shown in FIG. 2, a drop point DP is located at a portion of the pixel defining layer 190 having the smallest thickness. That is, the pixel defining layer 190 includes a smallest thickness portion 191 where the drop point DP is located, a greatest thickness portion 193 at the edges of the display substrate 110, and at least one middle thickness portion 192 having a middle thickness (intermediate thickness) between the smallest thickness portion 191 and the greatest thickness portion 193. Here, the middle thickness portion 192 can have a thickness that varies in several steps. By designing the pixel defining layer 190 as such in the first exemplary embodiment, the thickness of the pixel defining layer 190 is gradually increased in steps from the smallest thickness portion 191 to the greatest thickness portion 193, and the cross-section thereof has a step structure. Also, in the first exemplary embodiment, the smallest thickness portion 191 of the pixel defining layer 190 is disposed at the central part of the display substrate 110, and accordingly the drop point DP is also disposed at the central part of the display substrate 110. Also, the pixel defining layer 190 can be made out of a polyacryl-based resin, a polyimide-based resin, or a silica-based inorganic material.

[0024] Again referring to FIG. 1 and FIG. 2, the encapsulation substrate 210 is arranged opposite to the display substrate 110, thereby covering the organic light emitting element 70 and the driving circuit DC of the display substrate 110. The encapsulation substrate 210 includes a second substrate main body 211 made of a transparent material such as glass or plastic.

[0025] The sealant 350 is disposed along the edges of the display substrate 110 and the encapsulation substrate 210, thereby bonding the display substrate 110 to the encapsulation substrate 210. Here, the sealant 350 is disposed close to the greatest thickness portion 193 of the pixel defining layer 190.

[0026] The filler 300 is disposed between the display substrate 110 and the encapsulation substrate 210, thereby filling the space between the display substrate 110 and the encapsulation substrate 210. Also, the filler 300 may be made of a resin material, a liquid crystal material, or various other known materials.

[0027] The filler 300 fills the empty space between the display substrate 110 and the encapsulation substrate 210 so that the mechanical strength of the organic light emitting diode (OLED) display 101 can be improved. That is, the filler 300 occupies the inner part of the organic light emitting diode (OLED) display 101 so that the OLED display 101 is less vulnerable to damage upon external impact.

[0028] The filler 300 is applied by dripping a filler material onto the drop point DP disposed in the smallest thickness portion 191 of the pixel defining layer 190. The filler material can then be diffused to the edges of the display substrate 110. The thickness of the pixel defining

layer 190 is smallest at the location where the drop point DP is located, and is greatest at the edge of the display substrate 110 closest to the sealant 350. Accordingly, the diffusion and flow of the filler 300 from the drop point DP can be controlled by the contour of the pixel defining layer 190. That is, contour or profile of the pixel defining layer 190 suppresses excessively quick contact of the filler 300 with the sealant 350, allowing the sealant 350 to cure and harden without being influenced by the filler 300.

[0029] Also, the organic light emitting diode (OLED) display 101 may further include a plurality of spacers 250 formed on at least one of the display substrate 110 and the encapsulation substrate 210 to maintain an interval between the display substrate 110 and the encapsulation substrate 210. In the organic light emitting diode (OLED) display 101 according to the first embodiment of the present invention, the spacers 250 prevent the display substrate 110 and the encapsulation substrate 210 from contacting each other. Also, it is not necessary for the height of the spacers 250 to always be uniform across an entirety of the display substrate 110 and the encapsulation substrate 210.

[0030] The spacers 250 contact the display substrate 110 and the encapsulation substrate 210 to prevent the organic light emitting element 70 of the display substrate 110 from being damaged and to prevent deterioration from occurring.

[0031] Also, according to the location of the plurality of spacers 250, the spacers may have different lengths considering that the thickness of the pixel defining layer 190 varies with location. In particular, the length of the spacers 250 may be selected such that they have a virtual constant distance to the encapsulation substrate 210 or, in other words, that the sum of their length and the thickness of the pixel defining layer is virtual constant as shown in Figure 1. Here, the length of the spacers 250 means the height of the spacers 250 taken in a direction perpendicular to the surface of the display substrate 110.

[0032] Also, the plurality of spacers 250, together with the pixel defining layer 190, can control the diffusion and the flow of the filler 300 from the drop point DP to other locations on the display. Here, the width, height, shape, and density of the spacers 250 can be appropriately designed to control the diffusion and the flow of the filler 300.

[0033] With the above-described configuration, the durability of the organic light emitting diode (OLED) display 101 upon external impact is improved and the generation of the sealing deterioration is suppressed.

[0034] Next, a manufacturing method of an organic light emitting diode (OLED) display 101 according to the first exemplary embodiment will be described with reference to FIG. 2 to FIG. 4.

[0035] First, a display substrate 110 including a pixel defining layer 190 having several steps is formed. The pixel defining layer 190 has a smallest thickness portion where the drop point DP is located, and a greatest thickness portion disposed at the edge of the display substrate

110. That is, the pixel defining layer 190 includes a smallest thickness portion 191 where the drop point DP is located, a greatest thickness portion 193 disposed at the edge of the display substrate 110, and a middle thickness portion 192 having a middle height between the smallest thickness portion 191 and the greatest thickness portion 193. Also, in the first exemplary embodiment, the smallest thickness portion 191 of the pixel defining layer 190 and the drop point DP are disposed at the central part of the display substrate 110.

[0036] In this way, the thickness of the pixel defining layer 190 is gradually increased from the smallest thickness portion 191 where the drop point DP is disposed to the greatest thickness portion 193, and the cross-section of pixel defining layer 190 has steps.

[0037] Also, the display substrate 110 further includes an organic light emitting element 70, and the pixel defining layer 190 has a plurality of openings 195 defining the light emitting region of the organic light emitting element 70.

[0038] Next, a plurality of spacers 250 is formed on the pixel defining layer 190 of the display substrate 110. However, the first exemplary embodiment is not limited thereto, as the spacers 250 can instead be formed on an encapsulation substrate 210 that will be arranged opposite to the display substrate 110.

[0039] Also, the spacers 250 can be integrally formed with the pixel defining layer 190. That is, when forming the pixel defining layer 190 via a half-tone process, the pixel defining layer 190 and the spacers 250 may be formed together by controlling the exposure amount. Also, the pixel defining layer 190 and the spacers 250 can be made of a polyacryl-based resin, a polyimide-based resin, or a silica-based inorganic material.

[0040] Next, a sealant 350 is applied to the edges of the display substrate 110 on the display substrate 110. Here, the sealant 350 is disposed close to the greatest thickness portion 193 of the pixel defining layer 190. Nevertheless, it is not always necessary for the sealant 350 to be formed on the display substrate 110. Accordingly, the sealant 350 can instead be applied to the encapsulation substrate 210. When the sealant 350 is applied to the encapsulation substrate 210 and when the display substrate 110 and the encapsulation substrate 210 are then combined, the sealant 350 is located close to the greatest thickness portion 193 of the pixel defining layer 190.

[0041] Next, a filler material is initially dripped onto the drop point DP disposed in the smallest thickness portion 191 of the pixel defining layer 190, and the filler material is then diffused towards the edges of the display substrate 110. Here, the pixel defining layer 190 having a thickness that varies in several steps controls the diffusion and the flow of the filler 300 initially dripped onto the drop point DP. That is, the pixel defining layer 190 serves to delay contact of the filler 300 with the sealant 350. As a result, the pixel defining layer 190 minimizes the damage to sealant 350 caused by rapid contact of the filler

300 with the sealant 350 during the curing of the sealant 350.

[0042] Next, the display substrate 110 and the encapsulation substrate 210 are combined via a vacuum combining method with the sealant 350 and the filler 300 interposed therebetween. Then, the sealant 350 is hardened, thereby completely sealing the space between the display substrate 110 and the encapsulation substrate 210 from an exterior of the display.

[0043] Through this manufacturing method, the durability of the organic light emitting diode (OLED) display 101 against impact is achieved and the generation of sealant deterioration is suppressed.

[0044] Next, an internal structure of an organic light emitting diode (OLED) display 101 will be described with reference to FIGS. 5 and 6. FIG. 5 is a layout view showing a structure of a pixel focusing on a display substrate 110, and FIG. 6 is a cross-sectional view showing a display substrate 110 and an encapsulation substrate 210 taken along the line VI-VI of FIG. 5.

[0045] As shown in FIGS. 5 and 6, the display substrate 110 includes a switching thin film transistor 10, a driving thin film transistor 20, a capacitor 80, and an OLED 70 in each pixel. Here, the configuration including the switching thin film transistor 10, the driving thin film transistor 20, and the capacitor 80 is referred to as a driving circuit DC. Also, the display substrate 110 further includes gate lines 151 disposed according to one direction, data lines 171 intersecting and insulated from the gate lines 151, and a common power line 172. Here, one pixel may be defined by the gate line 151, the data line 171, and the common power line 172, but the present invention is not limited thereto.

[0046] The organic light emitting element 70 includes a pixel electrode 710, an organic emission layer 720 formed on the pixel electrode 710, and a common electrode 730 formed on the organic emission layer 720. Here, the pixel electrode 710 is a positive (+) electrode or anode and is a hole injection electrode, and the common electrode 730 is a negative (-) electrode or cathode and is an electron injection electrode. However, the present invention is not necessarily limited thereto, and depending upon the driving method of the organic light emitting diode display 101, the pixel electrode 710 may be a cathode and the common electrode 730 may be an anode. Holes and electrons are injected from the pixel electrode 710 and the common electrode 730 respectively into the organic emissive layer 720. When excitons, being combinations of the injected holes and electrons, shift from an excited state to a ground state, light is emitted.

[0047] Furthermore, in an organic light emitting diode display according to the first exemplary embodiment, the organic light emitting diode 70 emits light in the direction of the encapsulation substrate 210. That is, the organic light emitting diode display 101 is a front emission type. Here, for the organic light emitting element 70 to emit light in the direction of the encapsulation substrate 210,

the pixel electrode 710 is a reflective electrode and the common electrode 730 is a transparent or translucent electrode. However, in the first exemplary embodiment, the organic light emitting diode (OLED) display 101 is not limited to the front light emitting type. Accordingly, the organic light emitting diode (OLED) display 101 can instead be a rear light emitting type or a dual side light emitting type.

[0048] The capacitor 80 has a pair of capacitor electrode plates 158 and 178, and an interlayer insulating layer 160 interposed between the two capacitor electrode plates 158 and 178. The interlayer insulating layer 160 functions as a dielectric. The capacitance is determined depending upon electric charges charged at the capacitor 80 and the voltages applied to the two capacitor electrode plates 158 and 178.

[0049] The switching thin film transistor 10 includes a switching semiconductor layer 131, a switching gate electrode 152, a switching source electrode 173, and a switching drain electrode 174. The driving thin film transistor 20 includes a driving semiconductor layer 132, a driving gate electrode 155, a driving source electrode 176, and a driving drain electrode 177.

[0050] The switching thin film transistor 10 is used as a switch for selecting the pixels to emit light. The switching gate electrode 152 is connected to the gate line 151, the switching source electrode 173 is connected to the data line 171 and the switching drain electrode 174 is connected to one capacitor electrode plate 158 while being separated from the switching source electrode 173.

[0051] The driving thin film transistor 20 applies a driving voltage to the pixel electrode 710 to excite the organic emissive layer 720 of the first organic light emitting diode 70 in the selected pixel. The driving gate electrode 155 is connected to the capacitor electrode plate 158 that is connected to the switching drain electrode 174. The driving source electrode 176 and the other capacitor electrode plate 178 are each connected to the common power line 172. The driving drain electrode 177 is connected to the pixel electrode 710 of the organic light emitting diode 70 through a contact hole.

[0052] With the above structure, the switching thin film transistor 10 is operated by the gate voltage applied to the gate line 151, and transmits the data voltage applied to the data line 171 to the driving thin film transistor 20. A voltage corresponding to a difference between the common voltage applied to the driving thin film transistor 20 from the common power line 172 and the data voltage transmitted from the switching thin film transistor 10 is stored in the capacitor 80, and a current corresponding to the voltage stored at the capacitor 80 flows to the organic light emitting diode 70 through the driving thin film transistor 20 to thereby excite the organic light emitting diode 70. Also, the encapsulation substrate 210, for protecting the organic light emitting element 70, is disposed on the organic light emitting element 70, as shown in FIG. 6.

[0053] Next, the second exemplary embodiment of the

present invention will be described with reference to FIG. 7. As shown in FIG. 7, an organic light emitting diode (OLED) display 102 according to the second exemplary embodiment has two or more drop points DP. Also, a smallest thickness portion 291 of a pixel defining layer 290 including the two or more drop points DP may be formed. A greatest thickness portion 293 of the pixel defining layer 290 is disposed close to the sealant 350 at the edges of the display substrate 110. Instead of varying the thickness of the pixel defining layer 290 in steps as in the first embodiment, the thickness of the pixel defining layer 290 of the second embodiment is gradually increased from the smallest thickness portion 291 through a middle thickness portion 292 and to the greatest thickness portion 293.

[0054] The display substrate 110 has a rectangular shape and has a pair of long sides and a pair of short sides. The drop points DP are arranged in the direction parallel to the long sides of the display substrate 110.

[0055] When the drop point DP is disposed on one central position of the display substrate 110 of the rectangular shape as in the first embodiment, the required times it takes for the filler 300 to diffuse from the drop point DP to the long edge and the short edge of the display substrate 110 are different from each other. That is, the filler 300 reaches the sealant 350 formed along the long edge of the display substrate 110 before the filler 300 reaches the sealant 350 formed along the short edge. Accordingly, the influence of the filler 300 upon the curing of the sealant 350 becomes non-uniform so that deterioration of the sealant in the organic light emitting diode (OLED) display 101 may occur.

[0056] However, in the second exemplary embodiment, the organic light emitting diode (OLED) display 102 has two or more drop points DP, and the drop points DP are arranged in the direction parallel to the long edge of the display substrate 110 so that the difference in time it takes for the filler 300 to diffuse to and reach different portions of the sealant 350 is reduced with the design of the second embodiment of the present invention.

[0057] With the above-described configuration, the durability of the organic light emitting diode (OLED) display 102 against impact is improved and the occurrence of sealing deterioration is suppressed.

[0058] Also, a manufacturing method of the organic light emitting diode (OLED) display 102 according to the second exemplary embodiment is the same as the manufacturing method of the organic light emitting diode (OLED) display 101 according to the first exemplary embodiment except for the fact that the filler 300 is dripped onto two or more drop points DP instead of one and that the diffusion of the filler emanates from two or more drop points DP instead of one.

[0059] Next, the third exemplary embodiment of the present invention will be described with reference to FIG. 8. As shown in FIG. 8, an organic light emitting diode (OLED) display 104 according to the third exemplary embodiment includes a pixel defining layer 490 having a

cross-section having a gradual inclination. That is, the thickness of the pixel defining layer 490 is gradually and linearly increased from the portion where the drop point is located to the edge of the display substrate 110. In FIG. 8, the element number 495 indicates an opening in the pixel defining layer 490 defining light emitting regions of organic light emitting elements 70.

[0060] With the above-described configuration, when the filler 300 is dripped onto the drop point disposed on the smallest thickness portion of the pixel defining layer 490 and is diffused to the edges of the display substrate 110, the pixel defining layer 490 prevents the filler from quickly diffusing to the sealant 350 so that the filler 300 does not interfere with the curing process of the sealant 350.

[0061] Also, the manufacturing method of the organic light emitting diode (OLED) display 104 according to the third exemplary embodiment is the same as the manufacturing method of the organic light emitting diode (OLED) display 101 according to the first exemplary embodiment.

[0062] While this disclosure has been described in connection with what is presently considered to be practical exemplary embodiments, it is to be understood that the invention is not limited to the disclosed embodiments, but, on the contrary, is intended to cover various modifications and equivalent arrangements included within the scope of the appended claims.

Claims

1. An organic light emitting diode display (101, 102, 104), comprising:

a display substrate (110) including organic light emitting elements (70) and a pixel defining layer (190, 290, 490) having openings (195, 495) accommodating the organic light emitting elements (70), thus defining a light emitting region of the organic light emitting elements (70);
 an encapsulation substrate (210) arranged opposite to the display substrate (110);
 a sealant (350) arranged between the display substrate (110) and the encapsulation substrate (210) along their edges surrounding the pixel defining layer (190, 290, 490), such as to seal a space between the display substrate (110) and the encapsulation substrate (210) from an outside; and
 a filler (300) filling the space between the display substrate (110) and the encapsulation substrate (210),

characterized in that the pixel defining layer (190, 290, 490) comprises portions of which each has a thickness wherein different portions have different thicknesses, such that each portion surrounding one or more further portions

has a greater thickness than the surrounded further portions and an outmost surrounding portion of the pixel defining layer (190, 290, 490) closest to the sealant (350) at edges of the display substrate (110) and surrounding all other portions of the pixel defining layer (190, 290, 490) has a thickness that is greater than thicknesses of all the other portions of the pixel defining layer (190, 290, 490).

2. The organic light emitting diode display (101, 102, 104) of claim 1, wherein the portions are adjacent to each other and wherein the thickness of the pixel defining layer (190, 290, 490) increases to the edges of the display substrate (110) in a stepwise fashion.
3. The organic light emitting diode display (101, 102, 104) of claim 1, wherein the portions have gradually increasing thickness such that the thickness of the pixel defining layer gradually increases to the edges of the display substrate (110) in a linear fashion.
4. The organic light emitting diode display (101, 102, 104) of one of the preceding claims, further comprising a plurality of spacers (250) arranged on at least one of the display substrate (110) and the encapsulation substrate (210) to maintain an interval between the display substrate (110) and the encapsulation substrate (210).
5. The light emitting diode display (101, 102, 104) of one of the preceding claims, wherein the pixel defining layer (190, 290, 490) has at least two separate portions having a smallest thickness, the portions being provided in a direction parallel to a long side of the display substrate (110).
6. A method of manufacturing an organic light emitting diode display (101, 102, 104) according to one of claims 1 to 5, comprising:

providing a display substrate (110) including organic light emitting elements (70) and an encapsulation substrate (210);

forming a pixel defining layer (190, 290, 490) on the display substrate (110), the pixel defining layer (190, 290, 490) having openings (195, 495) accommodating the organic light emitting elements (70), thus defining a light emitting region of the organic light emitting elements (70); the pixel defining layer (190, 290, 490) comprises portions of each having a thickness wherein different portions have different thicknesses and that increases to the edges of the display substrate (110), such that each portion surrounding one or more further portions has a greater thickness than the surrounded further portions and an outmost surrounding portion of the pixel de-

- fining layer (190, 290, 490) closest to the edges of the display substrate (110) and surrounding all other portions of the pixel defining layer (190, 290, 490) has a thickness that is greater than thicknesses of all the other portions of the pixel defining layer (190, 290, 490);
 applying a sealant (350) along edges of at least one of the display substrate (110) and the encapsulation substrate (210) as to surround the pixel defining layer (190, 290, 490);
 dripping a filler (300) onto a portion of the pixel defining layer (190, 290, 490) having a relative smaller thickness than the portion of the pixel defining layer (190, 290, 490) having the greatest thickness;
 allowing the filler (300) to diffuse to edges of the display substrate (110); and
 sealing together the display substrate (110) and the encapsulation substrate (210) by combining together the display substrate (110) and the encapsulation substrate (210).
7. The method of manufacturing an organic light emitting diode display (101, 102, 104) of claim 6, further comprising forming a plurality of spacers (250) on at least one of the display substrate (110) and the encapsulation substrate (210).
8. The method of manufacturing an organic light emitting diode display (101, 102, 104) of claim 6 or 7, further comprising hardening the sealant (350) while combining the display substrate (110) and the encapsulation substrate (210) together.

Patentansprüche

1. Organische lichtemittierende Diodenanzeige (101, 102, 104), aufweisend:
- ein Anzeigesubstrat (101), aufweisend organische lichtemittierende Elemente (70) und eine Pixeldefinitionsschicht (190, 290, 490), die Öffnungen (195, 495), die die organischen lichtemittierenden Elemente (70) aufnehmen, aufweist, so dass ein lichtemittierender Bereich der organischen lichtemittierenden Elemente (70) definiert wird;
- ein Verkapselungssubstrat (210), das gegenüber dem Anzeigesubstrat (110) angeordnet ist;
- ein Dichtungsmittel (350), das zwischen dem Anzeigesubstrat (110) und dem Verkapselungssubstrat (210) entlang deren Rändern die Pixeldefinitionsschicht (190, 290, 490) umgebend angeordnet ist, so dass es einen Raum zwischen dem Anzeigesubstrat (110) und dem Verkapselungssubstrat (210) gegenüber einer Außenseite abdichtet; und

einen Füllstoff (300), der den Raum zwischen dem Anzeigesubstrat (110) und dem Verkapselungssubstrat (210) füllt,

dadurch gekennzeichnet, dass die Pixeldefinitionsschicht (190, 290, 490) Abschnitte aufweist, von denen jeder eine Dicke aufweist, wobei verschiedene Abschnitte verschiedene Dicken aufweisen, so dass jeder Abschnitt, der einen oder mehrere weitere Abschnitte umgibt, eine größere Dicke als die umgebenen weiteren Abschnitte aufweist, und ein äußerster umgebender Abschnitt der Pixeldefinitionsschicht (190, 290, 490), der dem Dichtungsmittel (350) an Rändern des Anzeigesubstrats (110) am nächsten ist und alle anderen Abschnitte der Pixeldefinitionsschicht (190, 290, 490) umgibt, eine Dicke aufweist, die größer als Dicken aller anderen Abschnitte der Pixeldefinitionsschicht (190, 290, 490) ist.

2. Organische lichtemittierende Diodenanzeige (101, 102, 104) nach Anspruch 1, wobei die Abschnitte zueinander benachbart sind, und wobei die Dicke der Pixeldefinitionsschicht (190, 290, 490) zu den Rändern des Anzeigesubstrats (110) hin schrittweise zunimmt.
3. Organische lichtemittierende Diodenanzeige (101, 102, 104) nach Anspruch 1, wobei die Abschnitte eine allmählich zunehmende Dicke derart aufweisen, dass die Dicke der Pixeldefinitionsschicht zu den Rändern des Anzeigesubstrats (110) hin allmählich linear zunimmt.
4. Organische lichtemittierende Diodenanzeige (101, 102, 104) nach einem der vorhergehenden Ansprüche, weiterhin aufweisend eine Vielzahl von Abstandhaltern (250), die auf dem Anzeigesubstrat (110) und/oder dem Verkapselungssubstrat (210) angeordnet sind, um einen Abstand zwischen dem Anzeigesubstrat (110) und dem Verkapselungssubstrat (210) aufrechtzuerhalten.
5. Lichtemittierende Diodenanzeige (101, 102, 104) nach einem der vorhergehenden Ansprüche, wobei die Pixeldefinitionsschicht (190, 290, 490) zumindest zwei separate Abschnitte, die eine kleinste Dicke aufweisen, aufweist, wobei die Abschnitte in einer zu einer Längsseite des Anzeigesubstrats (110) parallelen Richtung bereitgestellt werden.
6. Verfahren zur Herstellung einer organischen lichtemittierenden Diodenanzeige (101, 102, 104) nach einem der Ansprüche 1 bis 5, aufweisend:

Bereitstellen eines Anzeigesubstrats (110), das organische lichtemittierende Elemente (70) aufweist, und eines Verkapselungssubstrats (210);

Ausbildung einer Pixeldefinitionsschicht (190, 290, 490) auf dem Anzeigesubstrat (110), wobei die Pixeldefinitionsschicht (190, 290, 490) Öffnungen (195, 495), die die organischen lichtemittierenden Elemente (70) aufnehmen, aufweist, so dass ein lichtemittierender Bereich der organischen lichtemittierenden Elemente (70) definiert wird; wobei die Pixeldefinitionsschicht (190, 290, 490) Abschnitte aufweist, von denen jeder eine Dicke aufweist, wobei verschiedene Abschnitte verschiedene Dicken aufweisen, und die zu den Rändern des Anzeigesubstrats (110) hin zunimmt, so dass jeder Abschnitt, der einen oder mehrere weitere Abschnitte umgibt, eine größere Dicke als die umgebenen weiteren Abschnitte aufweist, und ein äußerster umgebender Abschnitt der Pixeldefinitionsschicht (190, 290, 490), der den Rändern des Anzeigesubstrats (110) am nächsten ist und alle anderen Abschnitte der Pixeldefinitionsschicht (190, 290, 490) umgibt, eine Dicke aufweist, die größer als die Dicken aller anderen Abschnitte der Pixeldefinitionsschicht (190, 290, 490) ist; Aufbringen eines Dichtungsmittels (350) entlang Rändern des Anzeigesubstrats (110) und/oder des Verkapselungssubstrats (210), so dass es die Pixeldefinitionsschicht (190, 290, 490) umgibt; Tropfen eines Füllstoffs (300) auf einen Abschnitt der Pixeldefinitionsschicht (190, 290, 490), der eine vergleichsweise kleinere Dicke aufweist als der Abschnitt der Pixeldefinitionsschicht (190, 290, 490), der die größte Dicke aufweist; Diffundieren-Lassen des Füllstoffs (300) zu Rändern des Anzeigesubstrats (110); und Miteinander-Versiegeln des Anzeigesubstrats (110) und des Verkapselungssubstrats (210) durch Miteinander-Kombinieren des Anzeigesubstrats (110) und des Verkapselungssubstrats (210).

7. Verfahren zur Herstellung einer organischen lichtemittierenden Diodenanzeige (101, 102, 104) nach Anspruch 6, weiterhin aufweisend die Ausbildung einer Vielzahl von Abstandhaltern (250) auf dem Anzeigesubstrat (110) und/oder dem Verkapselungssubstrat (210).
8. Verfahren zur Herstellung einer organischen lichtemittierenden Diodenanzeige (101, 102, 104) nach Anspruch 6 oder 7, weiterhin aufweisend das Härten des Dichtungsmittels (350), während das Anzeigesubstrat (110) und das Verkapselungssubstrat (210) miteinander kombiniert werden.

Revendications

1. Affichage à diodes électroluminescentes organiques (101, 102, 104) comprenant :

un substrat d'affichage (110) comprenant des éléments électroluminescents organiques (70) et une couche de définition de pixel (190, 290, 490) ayant des ouvertures (195, 495) logeant les éléments électroluminescents organiques (70), définissant ainsi une région d'émission de lumière des éléments électroluminescents organiques (70) ;

un substrat d'encapsulation (210) agencé à l'opposé du substrat d'affichage (110) ;

un agent de scellement (350) agencé entre le substrat d'affichage (110) et le substrat d'encapsulation (210) le long de leurs bords entourant la couche de définition de pixel (190, 290, 490), afin de sceller un espace entre le substrat d'affichage (110) et le substrat d'encapsulation (210) depuis un extérieur ; et

une matière de remplissage (300) remplissant l'espace entre le substrat d'affichage (110) et le substrat d'encapsulation (210),

caractérisé en ce que la couche de définition de pixel (190, 290, 490) comprend des parties, dont chacune a une épaisseur, dans laquelle différentes parties ont des épaisseurs différentes, de sorte que chaque partie entourant une ou plusieurs parties supplémentaires a une épaisseur supérieure aux parties supplémentaires entourées et une partie périphérique située le plus à l'extérieur de la couche de définition de pixel (190, 290, 490) la plus proche de l'agent de scellement (350) au niveau des bords du substrat d'affichage (110) et entourant toutes les autres parties de la couche de définition de pixel (190, 290, 490) a une épaisseur qui est supérieure aux épaisseurs de toutes les autres parties de la couche de définition de pixel (190, 290, 490).

2. Affichage à diodes électroluminescentes organiques (101, 102, 104) selon la revendication 1, dans lequel les parties sont adjacentes les unes par rapport aux autres et dans lequel l'épaisseur de la couche de définition de pixel (190, 290, 490) augmente jusqu'aux bords du substrat d'affichage (110) par palier.
3. Affichage à diodes électroluminescentes organiques (101, 102, 104) selon la revendication 1, dans lequel les parties ont une épaisseur progressivement croissante de sorte que l'épaisseur de la couche de définition de pixel augmente progressivement jusqu'aux bords du substrat d'affichage (110) d'une manière linéaire.

4. Affichage à diodes électroluminescentes organiques (101, 102, 104) selon l'une des revendications précédentes, comprenant en outre une pluralité de dispositifs d'espacement (250) agencés sur au moins l'un parmi le substrat d'affichage (110) et le substrat d'encapsulation (210) pour maintenir un intervalle entre le substrat d'affichage (110) et le substrat d'encapsulation (210). 5
5. Affichage à diodes électroluminescentes organiques (101, 102, 104) selon l'une des revendications précédentes, dans lequel la couche de définition de pixel (190, 290, 490) a au moins deux parties séparées ayant la plus petite épaisseur, les parties étant prévues dans une direction parallèle à un côté long du substrat d'affichage (110). 10 15
6. Procédé pour fabriquer un affichage à diodes électroluminescentes organiques (101, 102, 104) selon l'une des revendications 1 à 5, comprenant les étapes consistant à : 20

fournir un substrat d'affichage (110) comprenant des éléments électroluminescents organiques (70) et un substrat d'encapsulation (210) ; 25

former une couche de définition de pixel (190, 290, 490) sur le substrat d'affichage (110), la couche de définition de pixel (190, 290, 490) ayant des ouvertures (195, 495) logeant les éléments électroluminescents organiques (70), définissant ainsi une région d'émission de lumière des éléments électroluminescents organiques (70) ; la couche de définition de pixel (190, 290, 490) comprend des parties dont chacune a une épaisseur, dans laquelle différentes parties ont différentes épaisseurs, et qui augmente vers les bords du substrat d'affichage (110), de sorte que chaque partie entourant une ou plusieurs parties supplémentaires a une épaisseur supérieure aux parties supplémentaires entourées et une partie périphérique située le plus à l'extérieur de la couche de définition de pixel (190, 290, 490) la plus proche des bords du substrat d'affichage (110) et entourant toutes les autres parties de la couche de définition de pixel (190, 290, 490) a une épaisseur qui est supérieure aux épaisseurs de toutes les autres parties de la couche de définition de pixel (190, 290, 490) ; 30 35 40 45

appliquer un agent de scellement (350) le long des bords d'au moins l'un parmi le substrat d'affichage (110) et le substrat d'encapsulation (210) afin d'entourer la couche de définition de pixel (190, 290, 490) ; 50

laisser tomber goutte à goutte une matière de remplissage (300) sur une partie de la couche de définition de pixel (190, 290, 490) ayant une épaisseur relative inférieure à la partie de la couche de définition de pixel (190, 290, 490) ayant 55
- la plus grande épaisseur ;
- permettre à la matière de remplissage (300) de diffuser jusqu'aux bords du substrat d'affichage (110) ; et
- sceller ensemble le substrat d'affichage (110) et le substrat d'encapsulation (210) en combinant ensemble le substrat d'affichage (110) et le substrat d'encapsulation (210).
7. Procédé pour fabriquer un affichage à diodes électroluminescentes organiques (101, 102, 104) selon la revendication 6, comprenant en outre l'étape consistant à former une pluralité de dispositifs d'espacement (250) sur au moins l'un parmi le substrat d'affichage (110) et le substrat d'encapsulation (210).
8. Procédé pour fabriquer un affichage à diodes électroluminescentes organiques (101, 102, 104) selon la revendication 6 ou 7, comprenant en outre l'étape consistant à faire durcir l'agent de scellement (350) tout en combinant le substrat d'affichage (110) et le substrat d'encapsulation (210) ensemble.

FIG.1

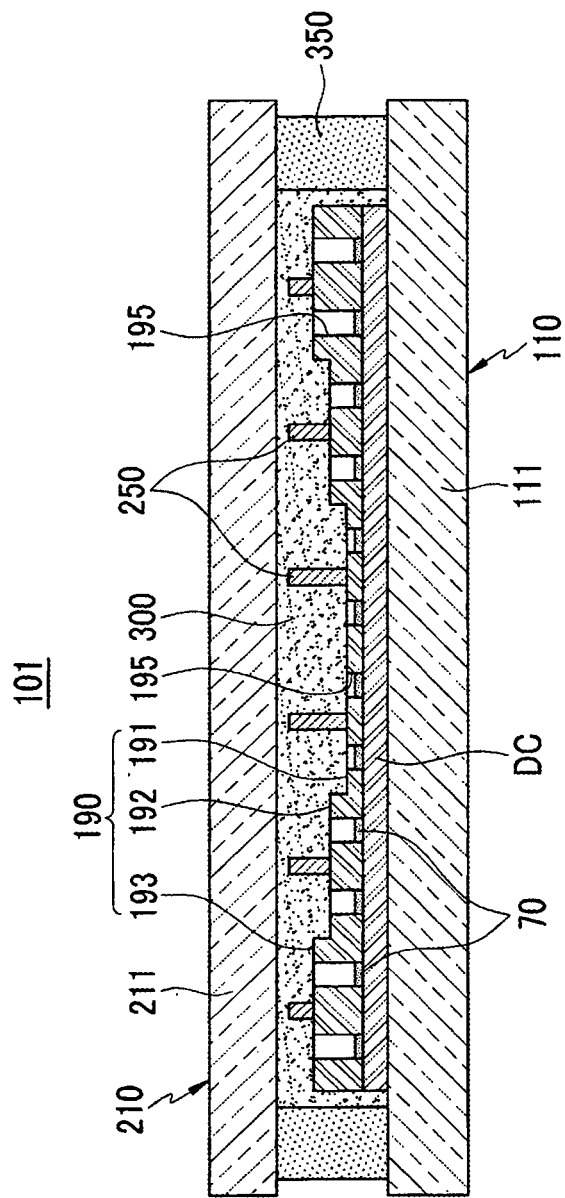


FIG.2

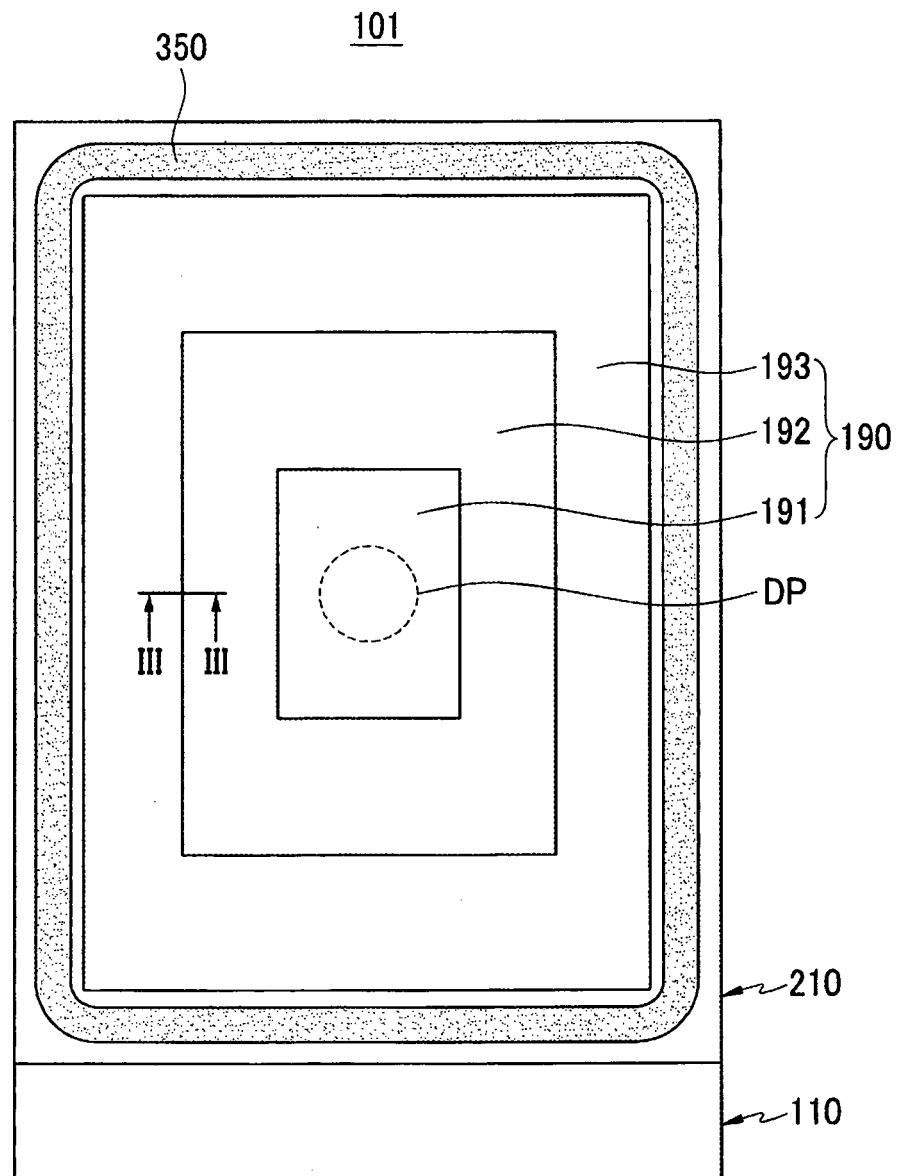


FIG.3

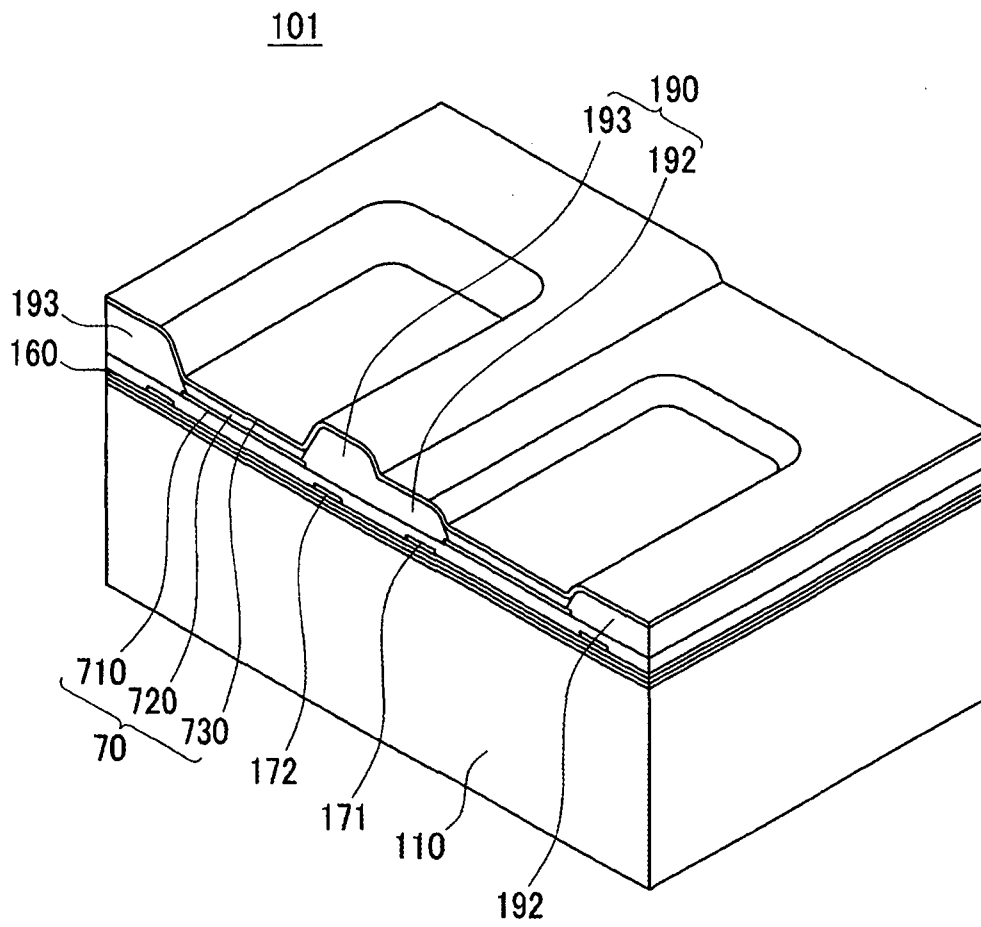


FIG.4

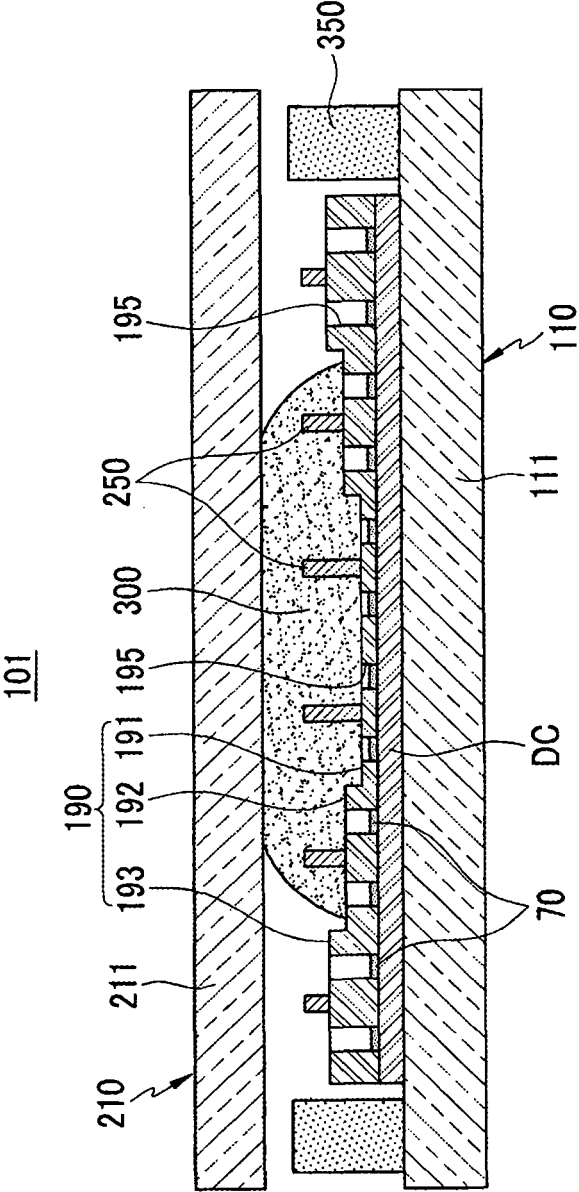


FIG.5

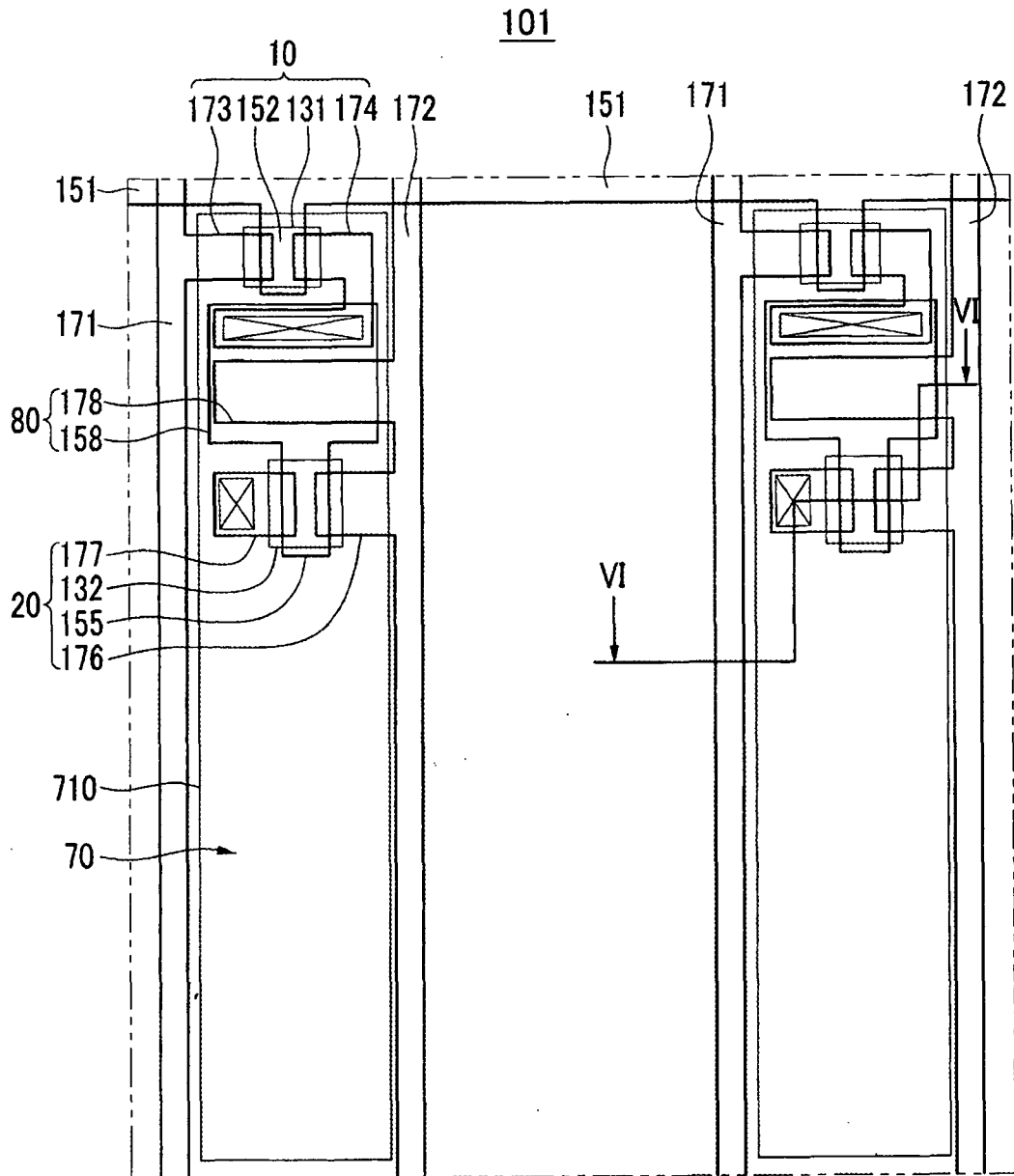


FIG. 6

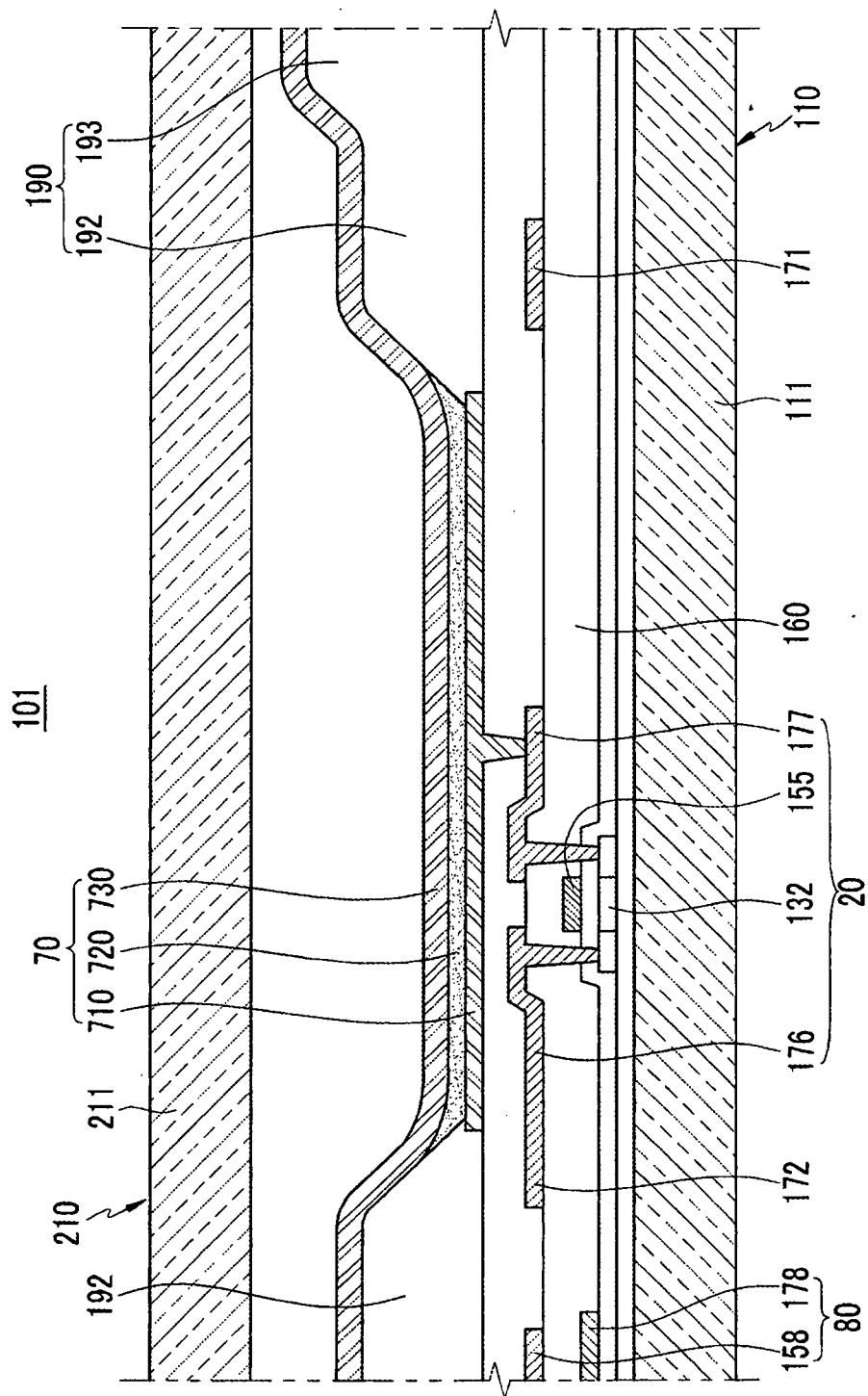


FIG.7

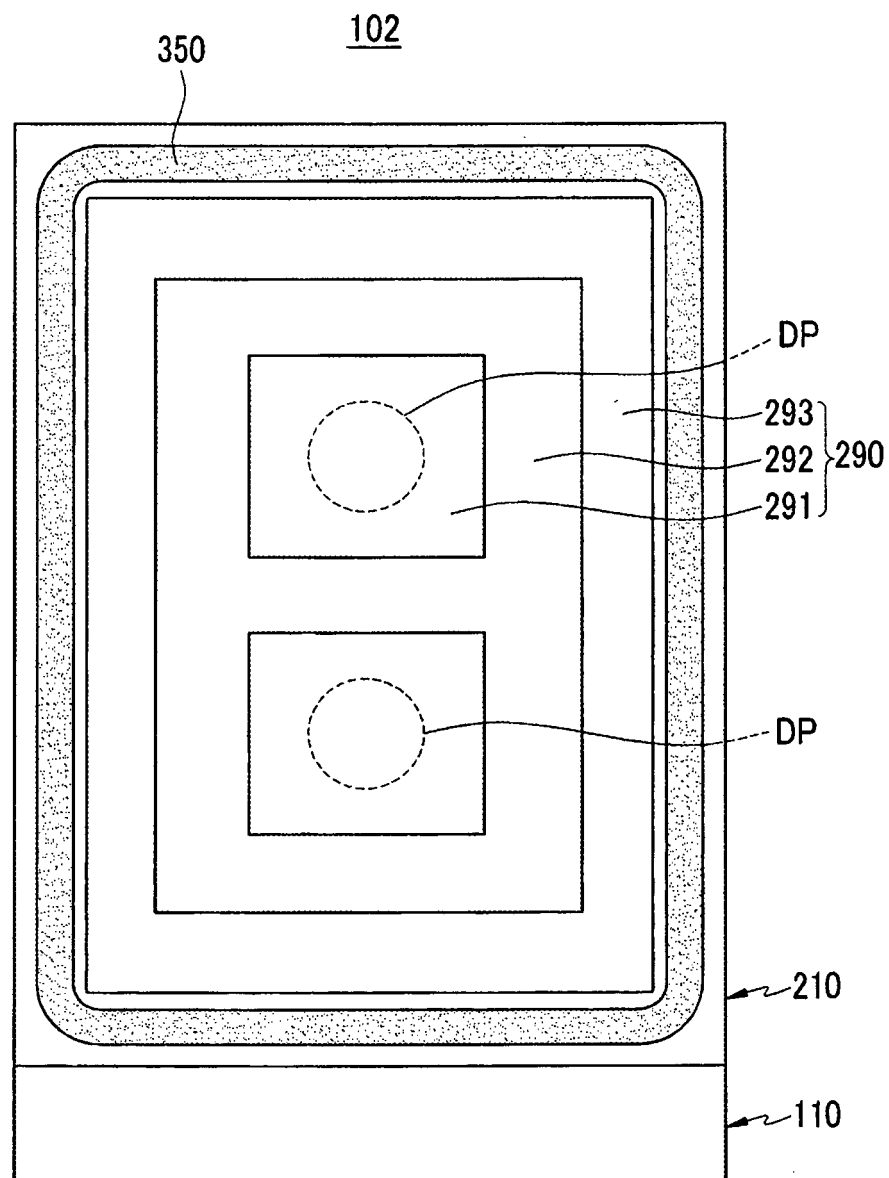
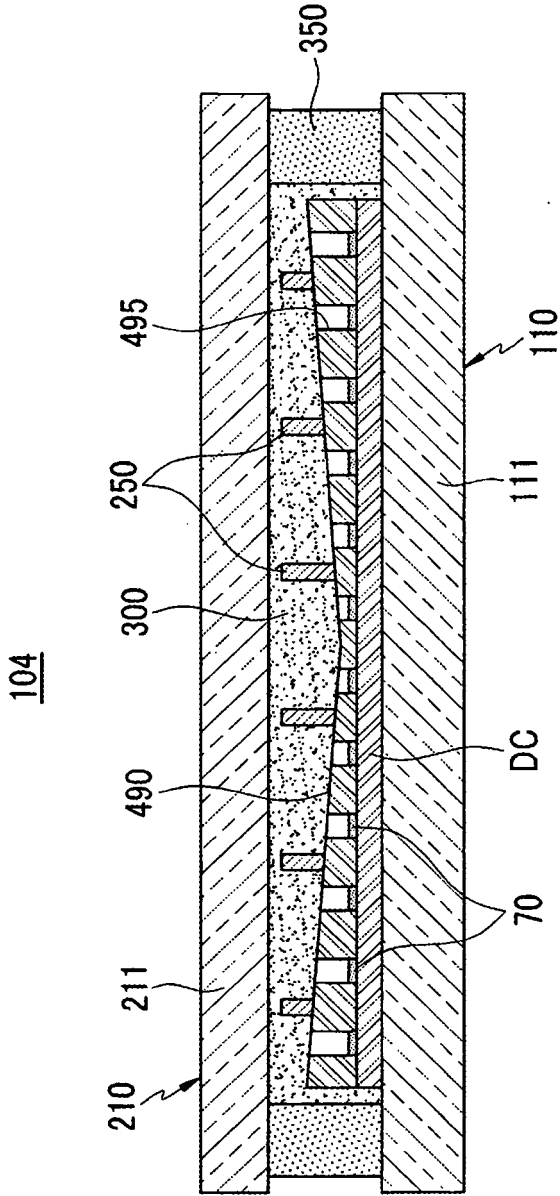


FIG.8



REFERENCES CITED IN THE DESCRIPTION

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专利名称(译)	有机发光二极管显示器及其制造方法		
公开(公告)号	EP2306545B1	公开(公告)日	2014-12-03
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[标]申请(专利权)人(译)	三星显示有限公司		
申请(专利权)人(译)	三星移动显示器有限公司.		
当前申请(专利权)人(译)	三星DISPLAY CO. , LTD.		
[标]发明人	LEE KYUNG JUN BAE SUNG JIN		
发明人	LEE, KYUNG-JUN BAE, SUNG-JIN		
IPC分类号	H01L51/52 H01L27/32		
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优先权	1020090063230 2009-07-10 KR		
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摘要(译)

一种有机发光二极管 (OLED) 显示器, 包括: 显示基板, 包括: 显示基板, 包括有机发光元件; 和像素限定层, 具有限定有机发光元件的发光区域的开口; 封装基板, 与所述有机发光元件相对设置。显示基板, 设置在显示基板和封装基板之间的边缘处的密封剂, 用于密封显示基板和封装基板之间的空间, 填充显示基板和封装基板之间的空间, 其中像素限定层具有随位置变化的厚度, 并且在显示基板的边缘处最靠近密封剂的像素限定层的一部分的厚度大于显示器的所有其他部分处的像素限定层的厚度。

FIG.1

